



Slurry and Chemical Flow Monitoring Upgrade

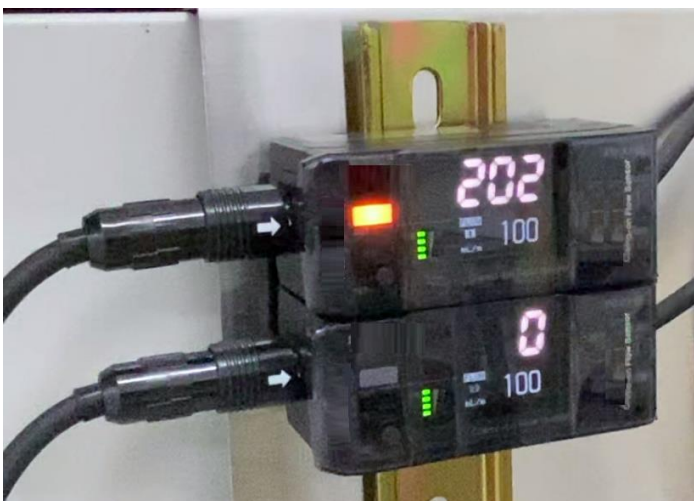
Overview

The Entrepix Slurry and Chemical Monitoring Upgrade provides a low cost, drop-in solution to ensure proper slurry flow while processing. This non invasive, no contact, upgrade can not cause shearing or obstruct slurry flow in any way. The upgrade is easy to install within a couple hours and interfaces with the existing Mirra software. The upgrade will stop wafer processing, then signal with a visual and audible alarm. Wafer recovery remains simple and unchanged from a normal system paused state.



Highlights

- Low cost solution with low risk.
- Will not effect slurry or chemical in any way.
- Can not slow or obstruct slurry flow or pressure .
- Automatically alarms and pauses polish process.
- Integrates with existing Mirra software .
- Real time slurry flow display and simple variable alarm set point selection.
- Alarm text and alarm trigger duration are customizable





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To see more part details on the slurry flow monitoring upgrade click the our video icon.



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